
**Nanotechnologies — Determination
of elemental impurities in samples of
carbon nanotubes using inductively
coupled plasma mass spectrometry**

*Nanotechnologies — Dosage des impuretés dans les nanotubes en
carbone (CNTs) par spectroscopie de masse à plasma induit (ICP-MS)*

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ISO copyright office
Ch. de Blandonnet 8 • CP 401
CH-1214 Vernier, Geneva, Switzerland
Tel. +41 22 749 01 11
Fax +41 22 749 09 47
copyright@iso.org
www.iso.org

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